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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of: Miwa KOZAWA et al. Group Art Unit: 1752

Application Number: 10/629,806 Examiner: Sin J. Lee

Filed: July 30, 2003 Confirmation Number: 9494

For: RESIST PATTERN THICKENING MATERIAL, PROCESS FOR

FORMING RESIST PATTERN, AND PROCESS FOR MANUFACTURING SEMICONDUCTOR DEVICE

Attorney Docket Number: 030923
Customer Number: 38834

INFORMATION DISCLOSURE STATEMENT UNDER 37 C.F.R. §1.97(c)(1)/(e)(1)

Commissioner for Patents P. O. Box 1450 Alexandria, VA 22313-1450 May 4, 2006

Sir:

Applicants direct the attention of the Patent and Trademark Office to the documents listed on the attached Form PTO/SB/08. A copy of each non - U.S. document is attached.

This Information Disclosure Statement (IDS) is being submitted after issuance of a first official action on the merits and expiration of the three month period following the filing date or the entry of the national stage for the above-captioned application, but prior to issuance of either a final official action or a Notice of Allowance.

The undersigned hereby certifies that each item of information contained in the IDS was first cited in any communication from a foreign patent office in a counterpart foreign application not more than three months prior to the filing of the IDS. A copy of the foreign communication citing the documents is attached.

Information Disclosure Statement under 1.97(c)(1) Attorney Docket No. 030923 Application No. 10/629,806

If there are any fees due in connection with the filing of this paper, please charge Deposit Account No. <u>50-2866</u>.

Respectfully submitted,

WESTERMAN, HATTORI, DANIELS & ADRIAN, LLP

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SY/mt

Enclosures: PTO/SB/08

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1 Document

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INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(use as many sheets as necessary)

	Complete if Known				
Ì	Application Number	10/629,806			
Ì	Confirmation Number	9494			
Ì	Filing Date	July 30, 2003			
Ì	First Named Inventor	Miwa KOZAWA et al.			
Ì	Art Unit	1752			
	Examiner Name	Sin J. Lee			
7	Attorney Docket Number	030923			

U.S. PATENT DOCUMENTS					
F	Cita	Document	Number	Publication Date MM-DD-YYYY	
Examiner Initials*		Number	Kind Code ² (if known)		Name of Patentee or Applicant of Cited Document
		US			

FOREIGN PATENT DOCUMENTS							
Examiner	Cite No.1	Foreign Patent Document			Publication Date	Name of Patentee or	Translation ⁶
Initials*		Country Code ³	Number ⁴	Kind Code ⁵ (if known)	MM-DD-YYYY	Applicant of Cited Document	Translation
<u></u> -	1	JP	2002-60641		02-26-2002	SHIN ETSU CHEM CO LTD	Yes
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NON PATENT LITERATURE DOCUMENTS				
Examiner Initials*	Cite No.1	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city, and/or country where published.	Translation ⁶	
	2	Japanese Office Action dated February 14, 2006 of a corresponding Japanese Application		
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Examiner Signature	Date Considered
Examiner Signature	

^{*}EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

¹Applicant's unique citation designation number (optional). ²See Kind Codes of USPTO Patent Documents at www.uspto.gov, MPEP 901.04 or in the comment box of this document. ³ Enter Office that issued the document, by the two-letter code (WIPO Standard ST. 3). ⁴For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the serial number of the patent document. ⁵Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST. 16 if possible. ⁶ Applicant is to indicate here if English language Translation is attached.